

substance: titanium oxide (TiO₂)

property: point defect thermodynamics in pure n-type TiO_{2-x} (rutile)

Theoretical reviews: [72K, 73D]. High-temperature studies of stoichiometry: Figs. 1, 2. Lines in the figures are derived from a model [67K] that assumes the concentration of conduction band electrons n arising from point defects only

$$n = 3[\text{Ti}_i^{3\cdot}] + 4[\text{Ti}_i^{4\cdot}] + 2[\text{V}_0^{\cdot\cdot}] \quad \text{with} \quad [\text{V}_0^{\cdot\cdot}] n^2 = k_1 p_{\text{O}_2}^{-1/2}, \quad [\text{Ti}_i^{3\cdot}] n^3 = k_2 p_{\text{O}_2}^{-1}, \quad [\text{Ti}_i^{4\cdot}] n = k_i [\text{Ti}_i^{3\cdot}]$$

with

$$k_1 = 4 \cdot 10^2 \exp(-105(\text{kcal/mol})/RT) [\text{atm}^{1/2}]$$

$$k_2 = 9.3 \cdot 10^9 \exp(210(\text{kcal/mol})/RT) [\text{atm}]$$

$$k_i = 3 \cdot 10^2 \exp(-35(\text{kcal/mol})/RT)$$

where the defect concentration in number of moles per mol of oxide is

$$x = (2([\text{Ti}_i^{3\cdot}] + [\text{Ti}_i^{4\cdot}]) + [\text{V}_0^{\cdot\cdot}]) / (1 + [\text{Ti}_i^{3\cdot}] + [\text{Ti}_i^{4\cdot}])$$

If oxygen vacancies are the dominant defect, $n \propto 2[\text{V}_0^{\cdot\cdot}]$ and $n \propto p_{\text{O}_2}^{-1/6}$. If $\text{Ti}_i^{4\cdot}$ is the dominant defect, $[\text{Ti}_i^{3\cdot}] \propto n[\text{Ti}_i^{4\cdot}] \propto n^2$, so that $n \propto p_{\text{O}_2}^{-1/5}$. If $\text{Ti}_i^{3\cdot}$ is dominant, $[\text{Ti}_i^{3\cdot}] \propto n$ and $n \propto p_{\text{O}_2}^{-1/4}$. For the application of this model to transport data, see documents on transport properties. For impurities in doped TiO₂, see other documents of this substance.

References:

- 62K Kofstad, P.: J. Phys. Chem. Solids 23 (1962) 1579.
- 64F Forland, K. S.: Acta Chem. Scand. 18 (1964) 1267.
- 65M Moser, J. B., Blumenthal, R. N., Whitmore, D. H.: J. Am. Ceram. Soc. 48 (1965) 384.
- 67A Alcock, C. B., Zadov, S., Steele, B. C. H.: Proc. Br. Ceram. Soc. 8 (1967) 231.
- 67K Kofstad, P.: J. Less-Common Met. 13 (1967) 635.
- 72K Kofstad, P.: Nonstoichiometry, Diffusion and Electrical Conductivity in Binary Metal Oxides, New York: Wiley, 1972.
- 73D DeFord, J. W., Johnson, O. W.: J. Appl. Phys. 44 (1973) 3001.

Fig. 1.

TiO_{2-x} . Composition parameter x vs. oxygen partial pressure in the temperature range 1000...1350°C. Full circles [67A], squares [64F], upwards triangles [65M], open circles [62K], downwards triangles [65M]. 1 atm = 101 325 Pa.

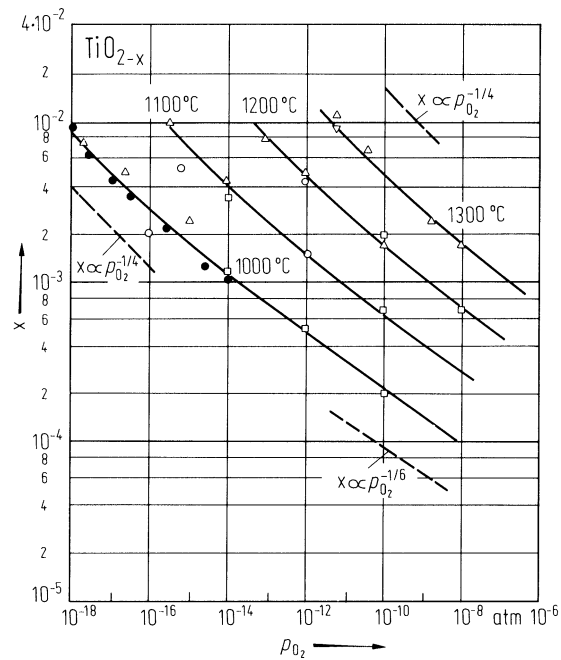


Fig. 2.

TiO_{2-x} . Composition parameter x vs. (reciprocal) temperature at various oxygen partial pressures. Symbols as in Fig. 1.

